



Defect level identification of ATLAS ITk Strip Sensors using DLTS

Christoph Klein

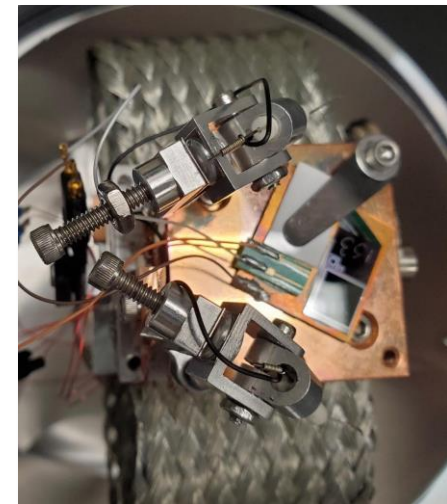
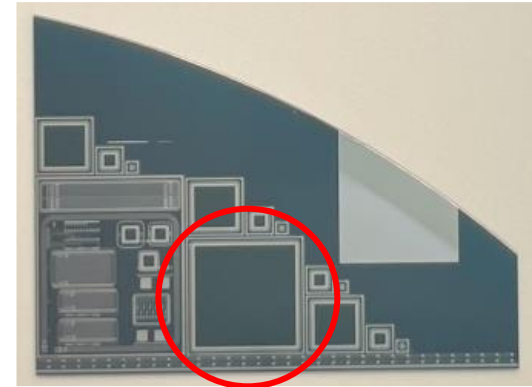
J. Dandoy, D. Duvnjak, C. Jessiman, J. Keller, T. Koffas, E. Staats, R. Vandusen, V. Fadeyev, Y. Unno, M. Ullan

13th Hiroshima Symposium, Vancouver, 3-8 December 2023



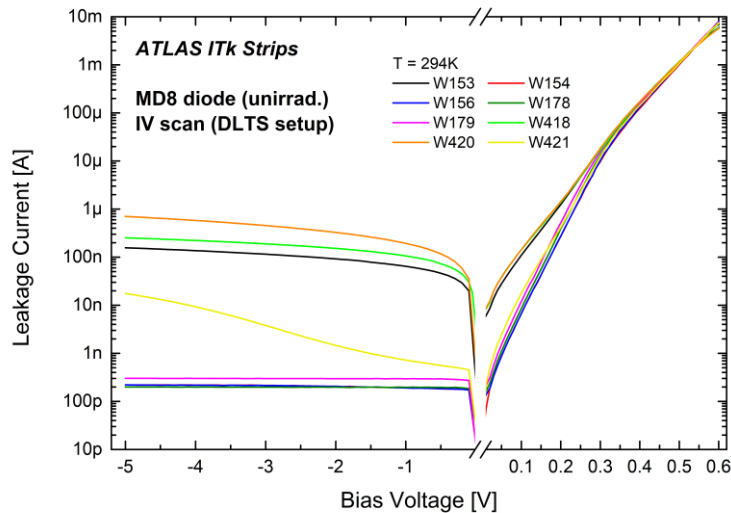
Motivation:

- implement trap parameters in TCAD (see [poster contribution by C. Jessiman](#))
 - precise simulations of irradiated ITk sensors
- measurements on MD8 diodes
 - square 8mm x 8mm n⁺-in-p diodes
 - produced as test structure on same wafers as main ITk Strip Sensors
- tests performed on unirradiated and irradiated devices
 - unirradiated halfmoons from batch with high current main sensors + reference samples from 'normal' batch
 - irradiated samples with irradiation done at CYRIC with 70 MeV protons
 - 3 different fluences (10% uncertainty) and annealed 80min@60°C:
4.57e14 n_{eq}/cm² 8.34e14 n_{eq}/cm² 1.54e15 n_{eq}/cm²
- samples mounted on heatsinks and wire bonded contacts for implant and GR



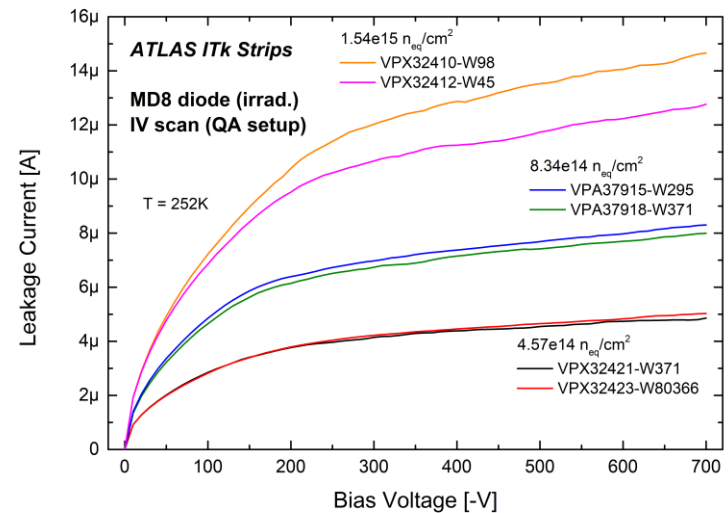


UNIRRADIATED



- IV curves taken at room temperature on DLTS setup
- W153-179 from a batch with high current main sensors; W418-421 for reference
- incidentally W153, W418, W420 with highest current

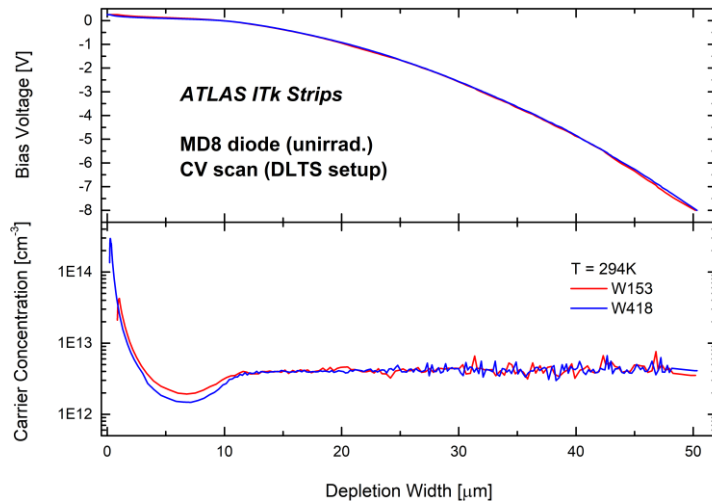
IRRADIATED



- QA results
- leakage current shows clear scaling with fluence
- higher currents allow for use of I-DLTS, but can limit usefulness of capacitance transients

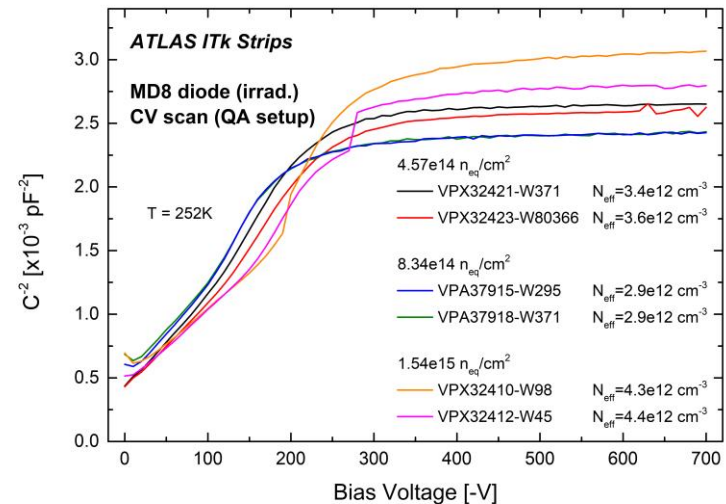


UNIRRADIATED



- CV scans did not show significant differences between samples
- depletion width and doping concentration can be derived from CV curves

IRRADIATED

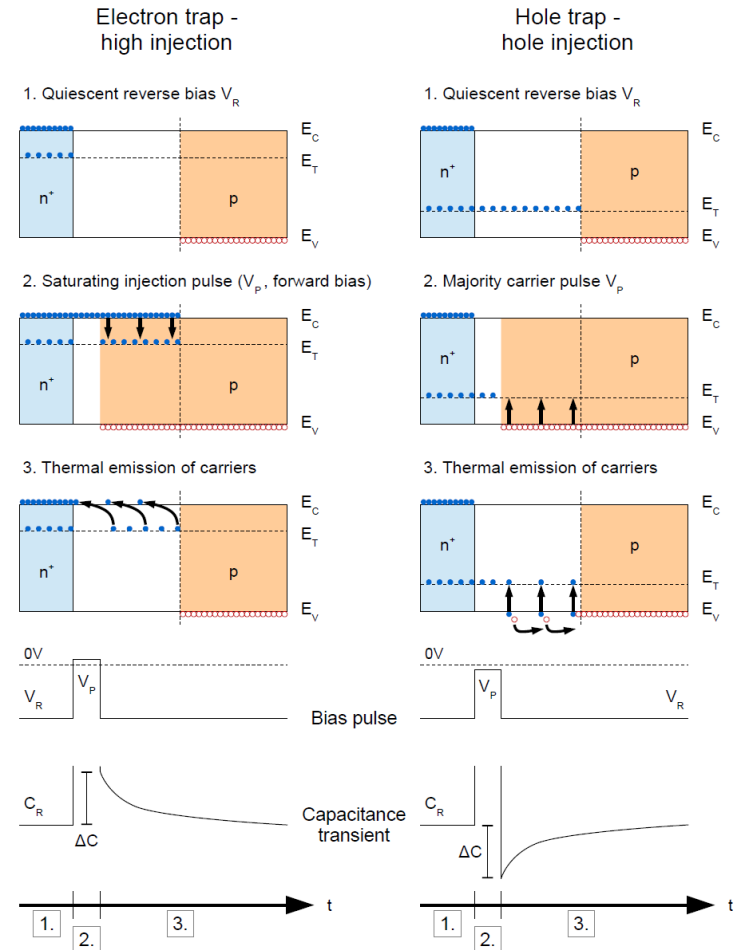


- full depletion still present at highest irradiation level
 - limited acceptor removal, N_{eff} similar to before irradiation
- DLTS setup can only bias up to 10V,
 - low bias readings of irradiated samples not useful for calculation of depletion width and carrier concentration



Measurement methods: DLTS/I-DLTS

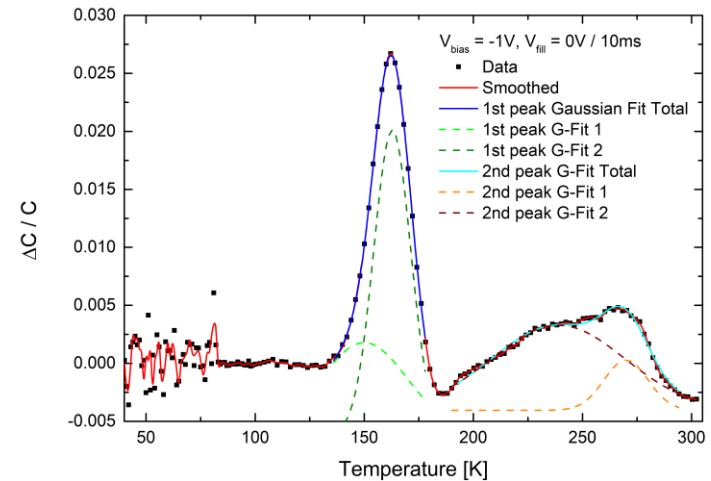
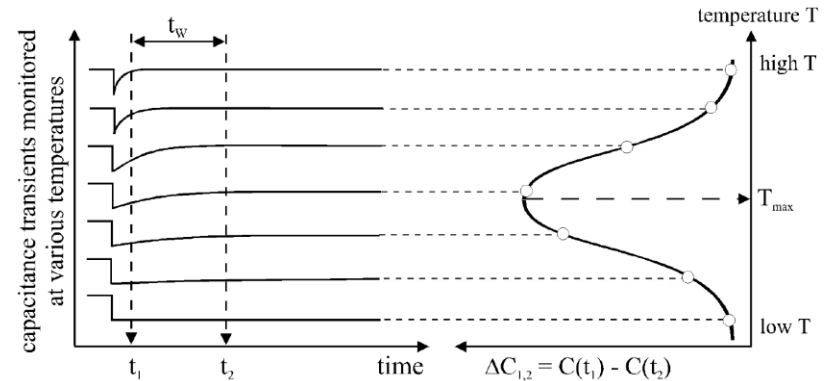
1. DUT is under constant reverse bias
2. filling pulse with specific voltage V_p and duration is applied, adjusted to trap states of interest
 - V_p as reduced reverse bias \rightarrow majority carrier traps (holes)
 - V_p slight forward bias \rightarrow minority carrier traps (electrons), if capture rate much larger than competing majority traps
3. bias back to prior level, measure transients
 - capacitance or current transients, depending on sample
 - usually average $O(100)$ transients per temperature point
 - plot ΔC or ΔI vs. temperature for fixed rate window corresponding to emission rate
 - analysing spectrum for varying rate window $[t_1; t_2]$ yields Arrhenius plot of trap levels





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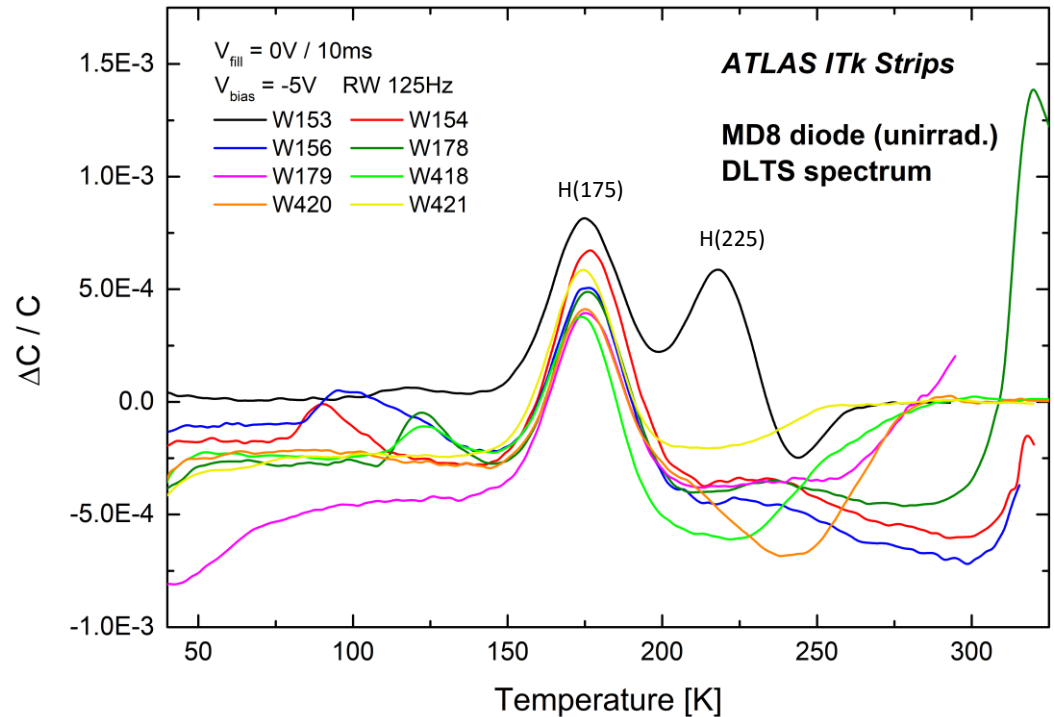
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Unirradiated diodes: DLTS spectra

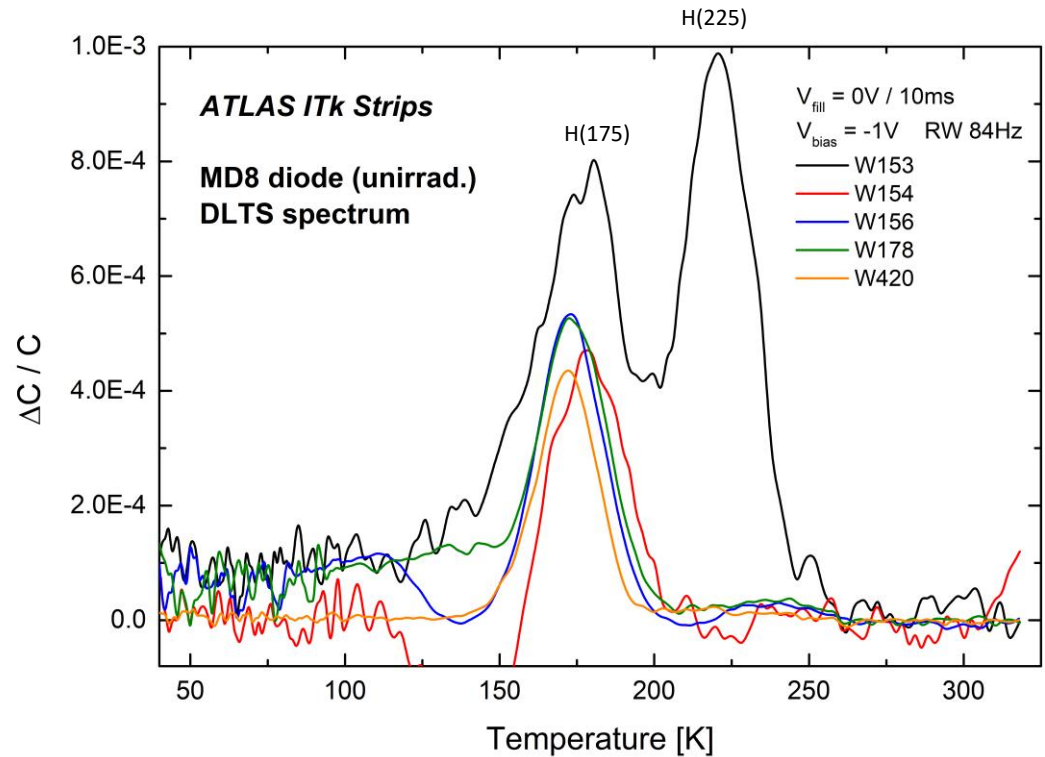
- DLTS measurements performed for different bias voltage and filling pulse settings
 - common trap at ~175K seen in all diodes
 - negative offset observed, mitigated with GR at GND
 - peaks at ~100K not consistent between different scan parameters; no clear Arrhenius plot
- **only true additional defect observed for W153 at ~225K**
 - confirmed over multiple runs and 2 diode samples





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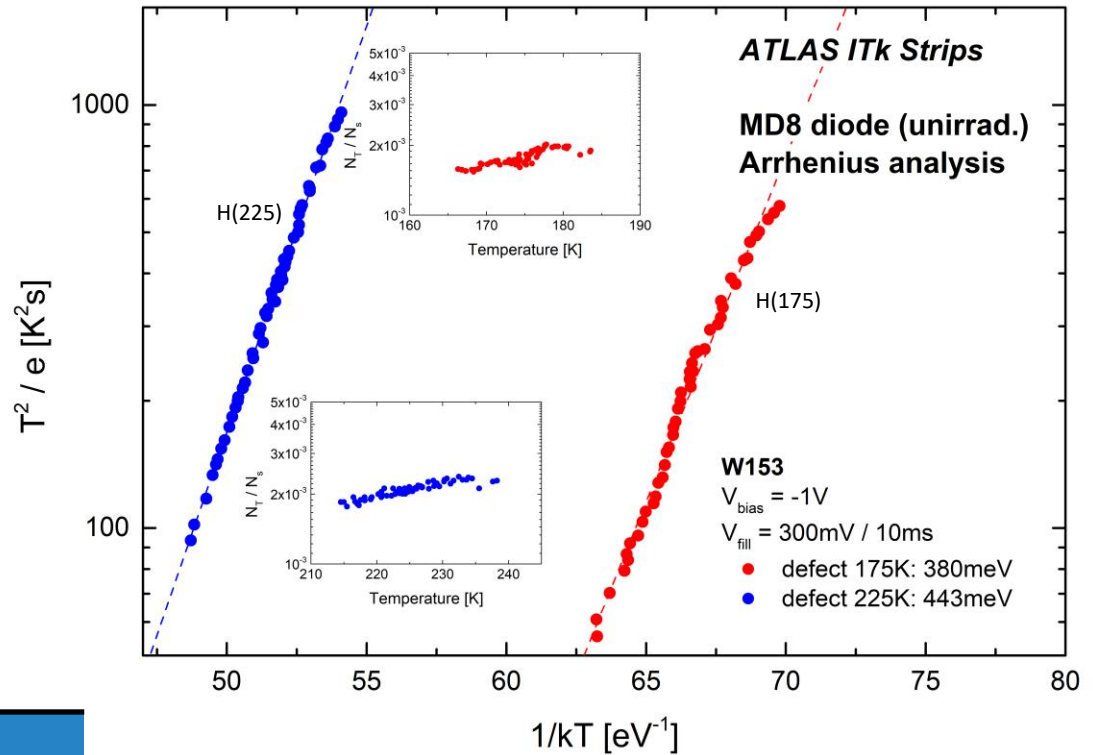
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Unirradiated diodes: Arrhenius analysis

- good trap saturation for 10ms filling pulse
 - flat relative trap concentration as indicator
- increased transient amplitude for larger bias
 - no changes to overall spectrum
- Arrhenius plots from rate window analysis
 - derive trap parameters from linear fits



T_{median} [K]	E_{T} [meV]	σ [cm ²]
175 (common)	310 – 390	$10^{-14} - 10^{-13}$
225 (W153 only)	443 ± 6	$7.5 \times 10^{-15} \pm 1.4X$

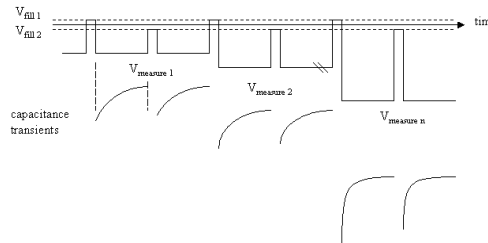
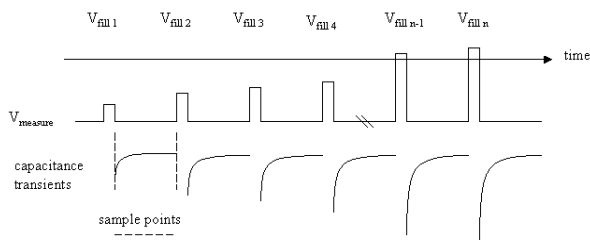
$$\ln(\tau_e T^2) = -\ln(\sigma_{n,p}^{\text{eff}} \Gamma_{n,p}) + \frac{E_A}{k_B T}$$



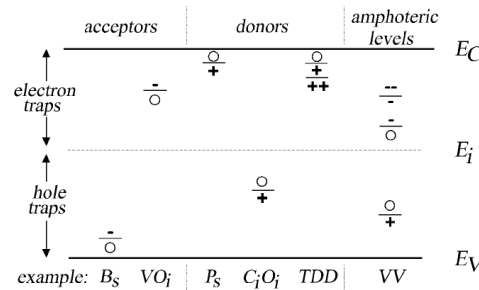
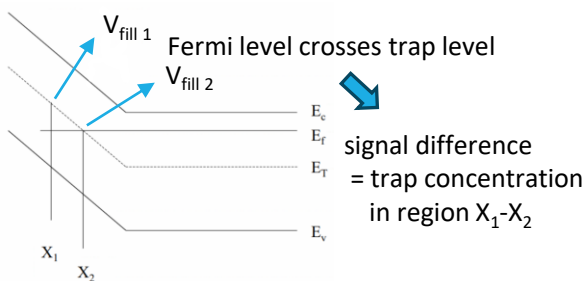
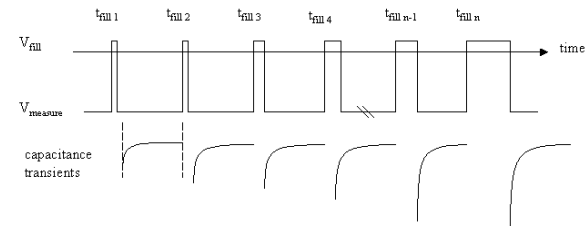
Measurement methods: DDLTS, Capture Kinematics



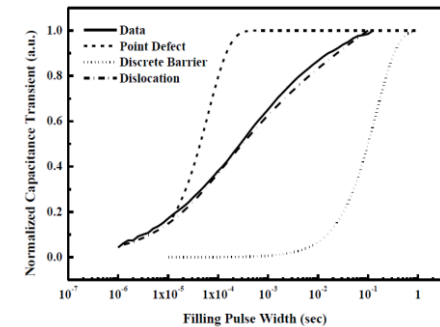
- Double-Pulse DLTS (DDLTS) measured at temperature of observed trap
- progressively increasing filling pulse at fixed bias
⇒ **deep level trap profile**
- fixed pair of filling pulses at increasing measurement bias
⇒ **field strength dependence**;
indicates acceptor/donor state



- increasing filling pulse duration
⇒ **capture kinematics**;
defect type



M. Moll, Ph.D. thesis

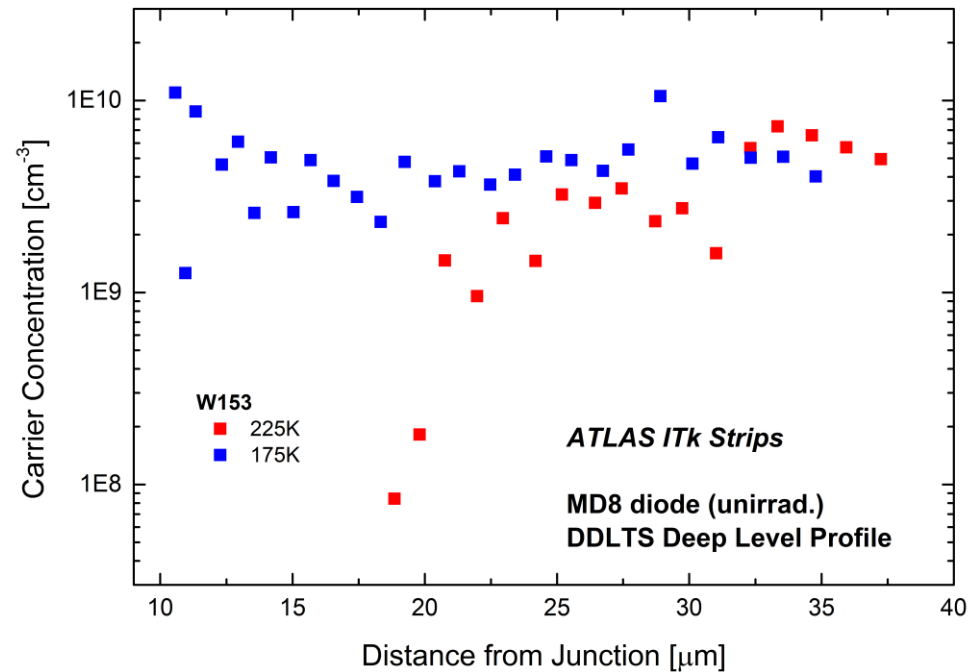
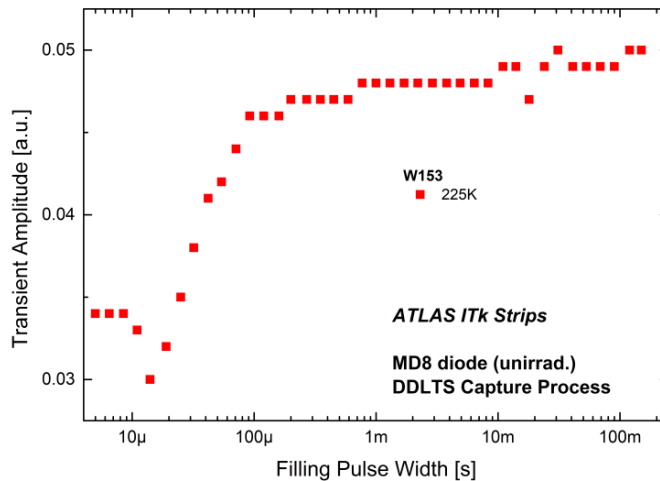


all other figures: Semetrol DLTS Manual



Unirradiated diodes: deep level profile & capture process

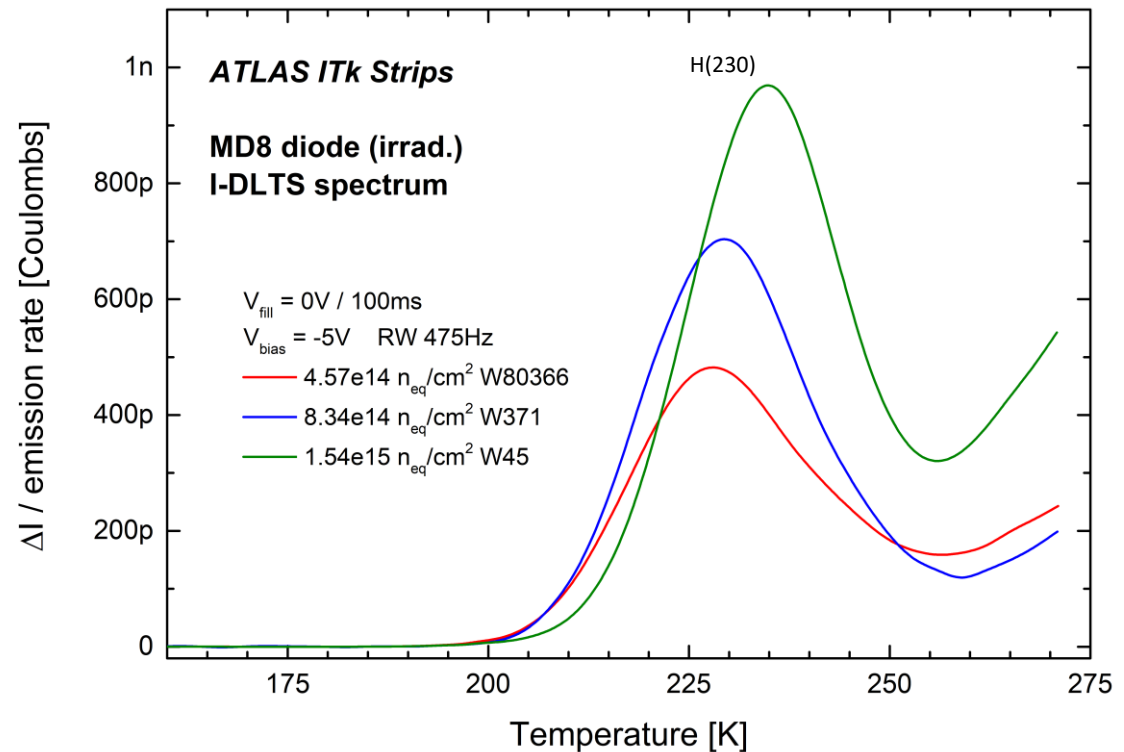
- 175K trap has constant concentration throughout depletion width
- 225K trap has decreased concentration close to junction
- trap saturation plateaus for filling pulse $\geq 1\text{ms}$
 - observed dependence indicates point defect





Irradiated diodes: I-DLTS spectra

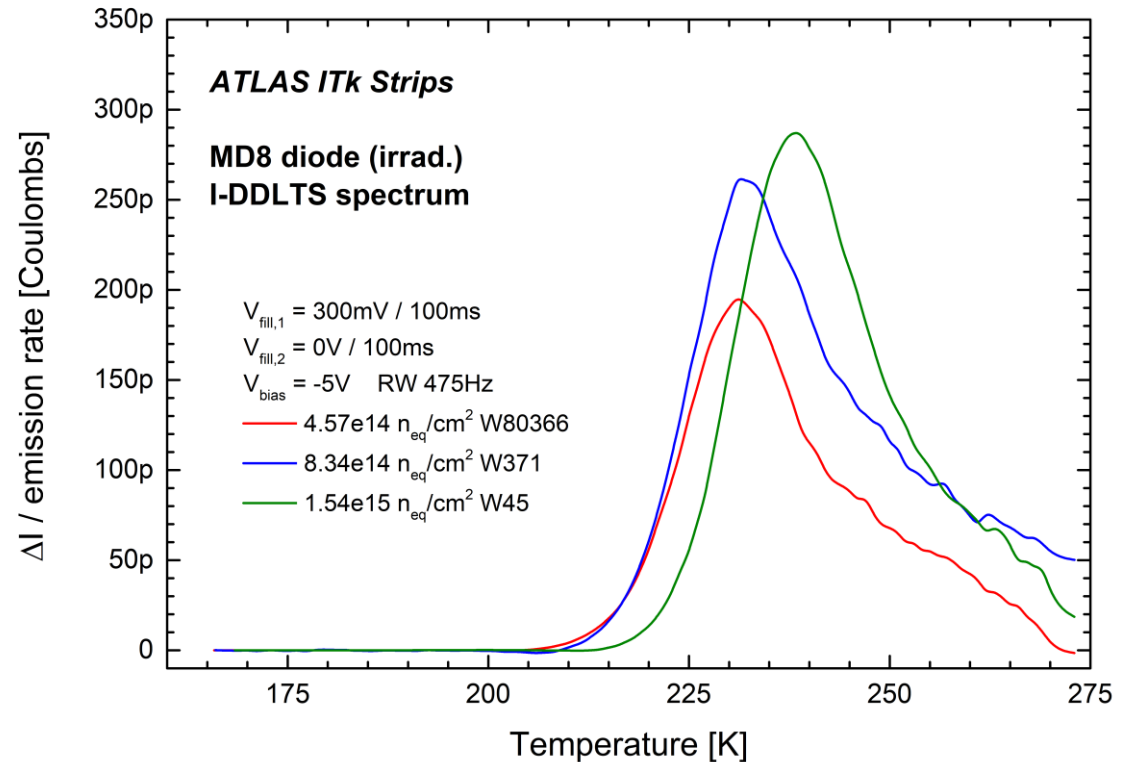
- capacitance transients did not yield reliable results
 - insufficient trap saturation, high trap concentration
 - exponential increase in capacitance for $T > 260\text{K}$
- I-DLTS spectra very clean
 - peak $>270\text{K}$ could not be fully explored due to high current
- slight shift of median peak temperature
- additional traps observed using injection pulse in double-pulse setting





Irradiated diodes: I-DLTS spectra

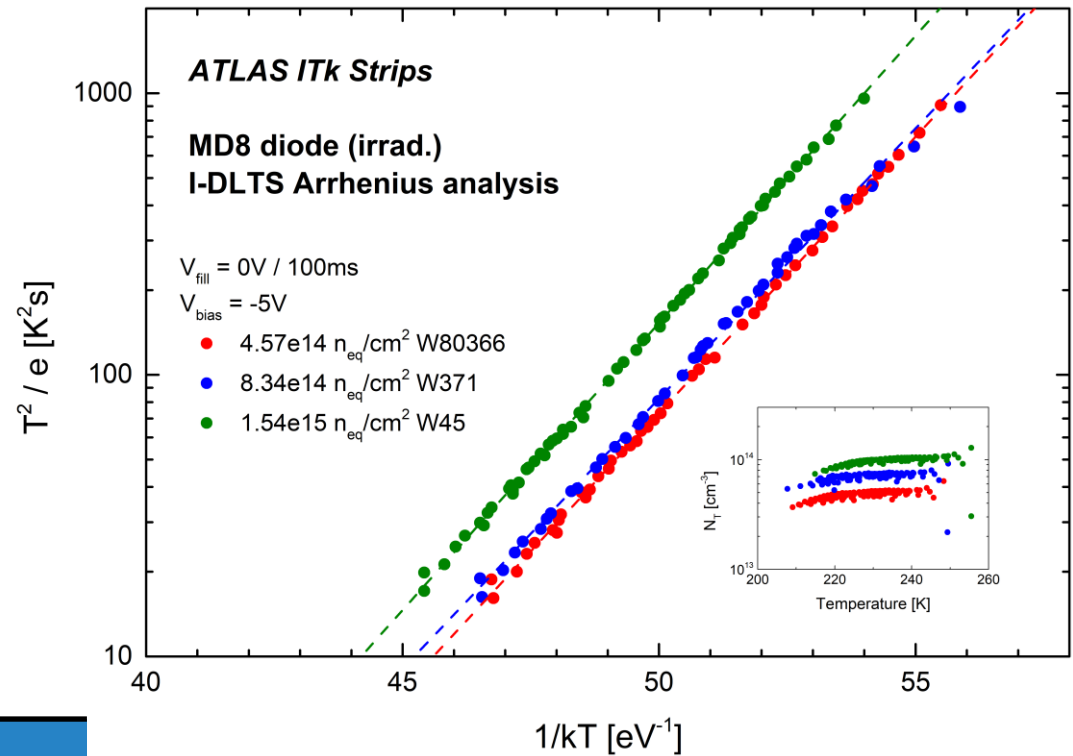
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Unirradiated diodes: Arrhenius analysis

- good trap saturation for 100ms filling pulse
- higher trap concentrations in devices irradiated to higher fluences
- no significant variation in trap parameters with higher fluence



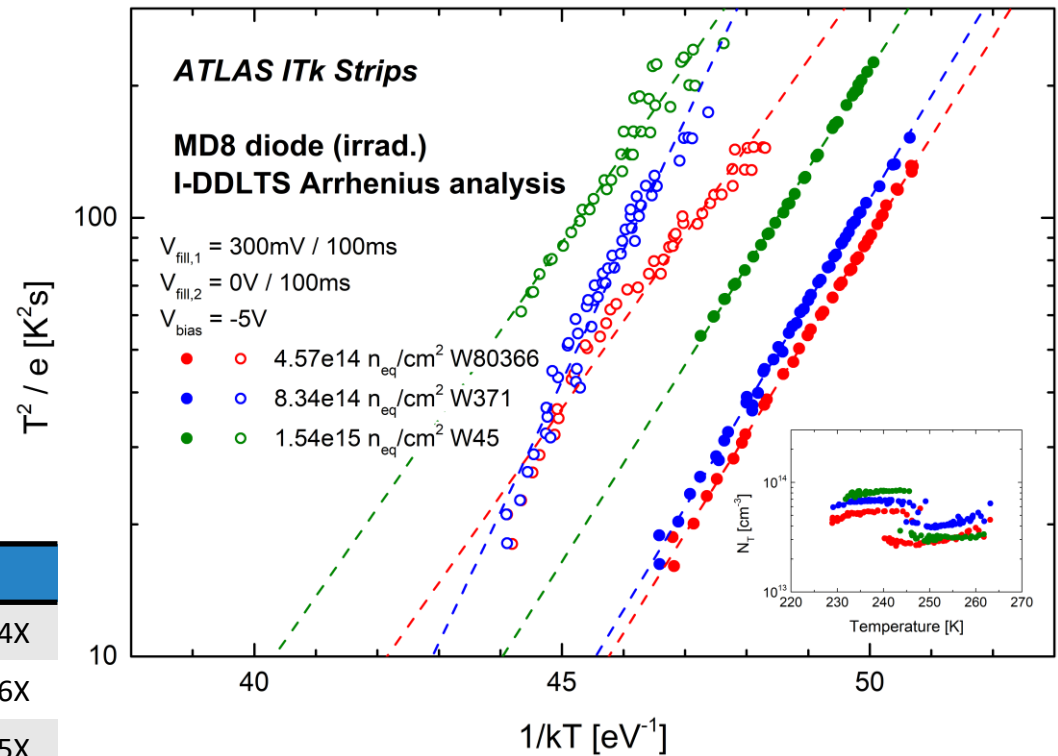
Φ [$n_{\text{eq}}/\text{cm}^2$]	T_{peak} [K]	E_{T} [meV]	σ [cm^2]
4.57e14	229	452 ± 4	2.7 x 10 ⁻¹⁴ ± 1.2X
8.34e14	228	442 ± 7	1.5 x 10 ⁻¹⁴ ± 1.5X
1.54e15	233	469 ± 3	3.2 x 10 ⁻¹⁴ ± 1.2X



Irradiated diodes: I-DLTS Arrhenius analysis

- forward injection pulse
 - remove large signal with double-pulse measurement
- 2-Gaussian deconvolution yields second trap contribution in peak flank
 - larger uncertainties on fit results of secondary peak component

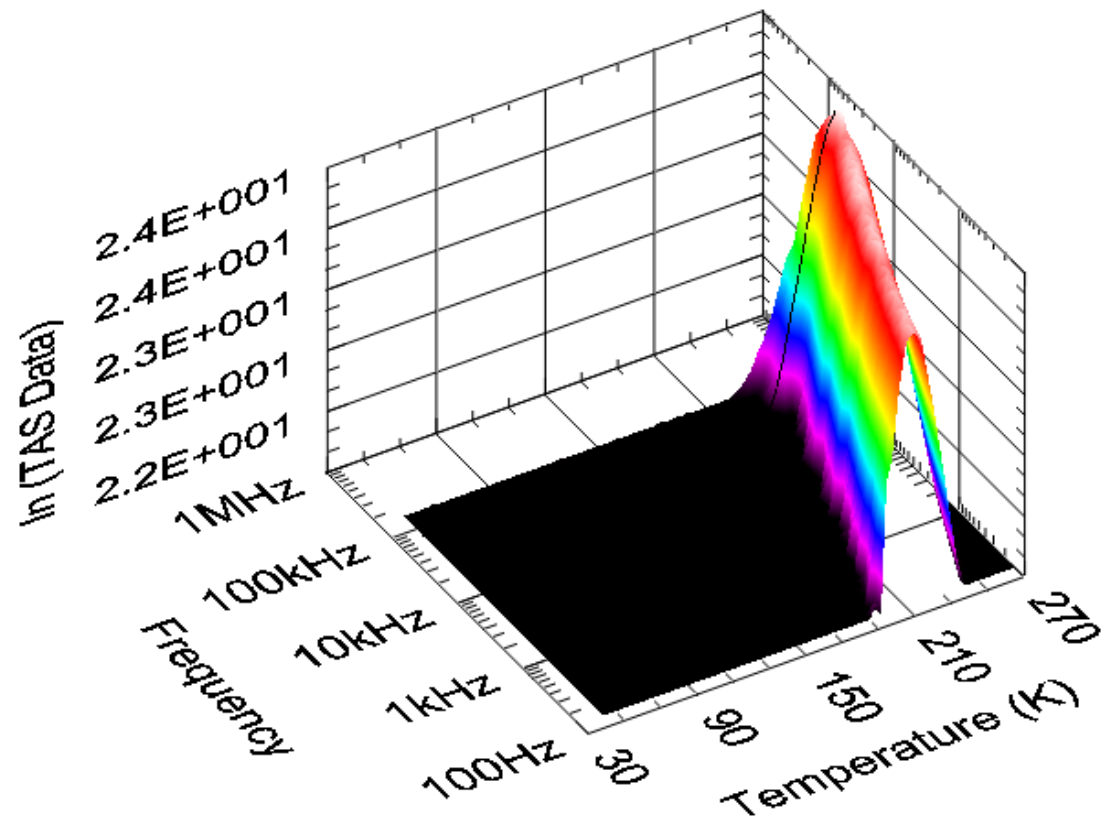
Φ [n_{eq}/cm^2]	T_{peak} [K]	E_T [meV]	σ [cm^2]
4.57e14	234	521 ± 7	$6.9 \times 10^{-13} \pm 1.4X$
	248	457 ± 28	$7.3 \times 10^{-15} \pm 3.6X$
8.34e14	237	539 ± 9	$1.4 \times 10^{-12} \pm 1.5X$
	254	686 ± 42	$1.9 \times 10^{-10} \pm 6.8X$
1.54e15	238	516 ± 6	$2.3 \times 10^{-13} \pm 1.4X$
	251	465 ± 41	$4.2 \times 10^{-15} \pm 6.5X$





Measurement methods: TAS

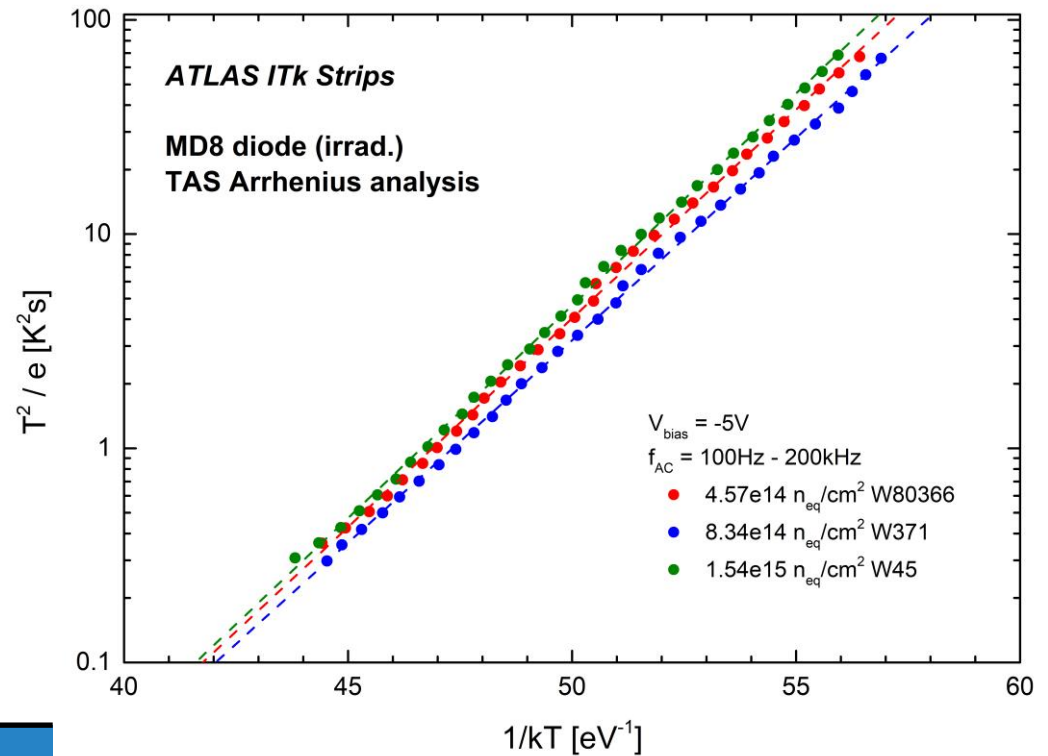
- Thermal Admittance Spectroscopy (TAS)
- measure $C/R/G/Phase$ as a function of temperature and frequency
 - steady-state measurement
 - defect contribution depending on test signal frequency and temperature
- steps in C or peak in G/R temperature dependence indicate thresholds for new traps contributing
 - steps/peaks yield Arrhenius plots of corresponding trap states





Irradiated diodes: TAS

- TAS yielded good results for irradiated diodes
 - no need to optimize filling pulse parameters for trap saturation
- trap parameters consistent with results from I-DLTS
 - no changes at different levels of irradiation



Φ [n_{eq}/cm^2]	T_{median} [K]	E_T [meV]	σ [cm^2]
4.57e14	230	449 ± 6	4.2 × 10 ⁻¹³ ± 1.3X
8.34e14	228	435 ± 4	2.7 × 10 ⁻¹³ ± 1.2X
1.54e15	232	456 ± 5	5.4 × 10 ⁻¹³ ± 1.3X



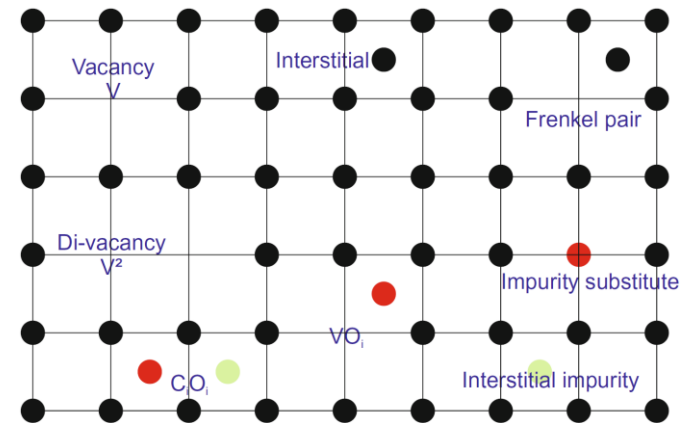
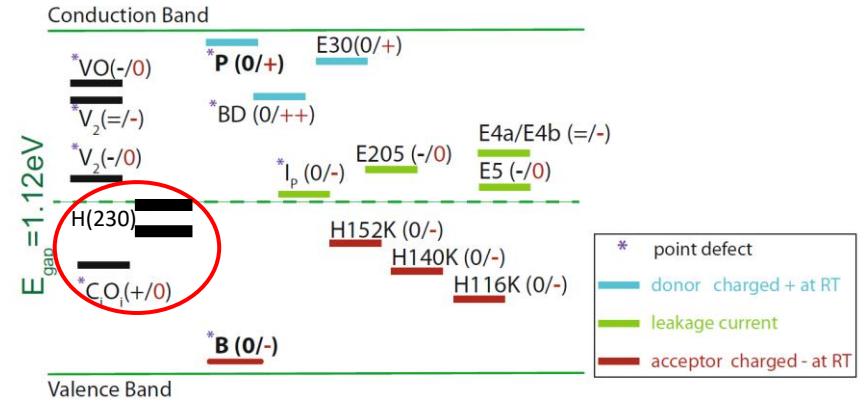
Discussion and Conclusion

Discussion

- T_{peak} and E_T of common H(175) defect in unirrad. diodes consistent with **interstitial carbon - interstitial oxygen (C_iO_i) complex** and other carbon-related defects (e.g. K-centre/ VOC complex)
- common H(230) defect in irradiated diodes consistent with reported **vacancy-clusters**
 - H(225) defect in unirrad. W153 has similar parameters
 - also found in CMS test structures with major contribution to high leakage current A. Junkes, Ph.D. thesis

Conclusion

- multiple trap parameters obtained for both unirradiated and irradiated diode samples of ITk Strip Sensors
- DLTS setup proven effective
 - standard C-DLTS and double-pulse variants yield precise results for unirradiated devices
 - I-DLTS and TAS more effective in highly irradiated samples due to significant trap concentration



Acknowledgements:
 This work was supported by the Canada Foundation for Innovation and the Natural Sciences and Engineering Research Council of Canada. This work is part of the Spanish R&D grant PID2021-1263270B-C22, funded by MCIN/AEI/10.13039/501100011033 / FEDER, UE. The work at SCIPP was supported by the US Department of Energy, grant DE-SC0010107.

Backup



Double-Pulse DLTS (DDLTS): capture process

- transients with filling pulse from 5 μ s to 200ms
- trap saturation for filling pulse ≥ 1 ms

